

AEC/APC Symposium Asia 2023 Program

*program schedule is subject to change.

		Chair	Paper#	Title	Speaker	Affiliation
Hitotsubashi Memorial Hall						
9:15	9:45			Registration Starts / Door Open		
Opening & Tutorial 1 Speech						
9:45	9:50	Hirai Toshiya KOKUSAI ELECTRIC		Opening Remarks from AEC/APC Asia	Hidetaka Nishimura	Renesas Electronics
9:50	9:55			Program Outline	Hidenori Kakinuma	Kioxia Corporation
9:55	10:40		Tutorial-1	<ONLINE> Practical molecular, material and process design and process control with artificial intelligence and machine learning		Hiromasa Kaneko
Session 1						
10:40	11:00	Hisato Tanaka Tokyo Electron	Takashi Kurosawa Azbil	GX-018	Smart Subfab Transformation using Context-Based Control	Holland Smith INFICON
11:00	11:20			PTL-013	Unified Platform for detecting faults governed by Process Controls	Vishali Ragam Applied Materials
11:20	11:40			DA-016	Mixed-type Defect Pattern Classifications	Takumi Maeda University of Tsukuba
11:40	12:00			YM-009	Defective Wafer Map Classification for Unknown Patterns Using Image Generation Model	Seima Sakaguchi Mie University
12:00	13:00	Lunch Break & Supplier Exhibition				
Keynote Speech						
13:00	13:45	Hidenori Kakinuma Kioxia	Keynote	The Future of Computing - Bits/Neurons/Qubits -	Shintaro Yamamichi	IBM Research -Tokyo, IBM Japan
Session2						
13:45	14:05	Takahiro Tsuchiya United Semiconductor Japan	Tomoya Tanaka Tower Partners Semiconductor	PTL-007	Machine Learning Based Virtual Metrology for Effective Process Control in High Product Mix Manufacturing	Hyung Joo Lee Siemens EDA
14:05	14:25			PTL-019	RF sensing method to detect low open area end point	Chuhua Song INFICON
14:25	14:45			PTL-008	Comparison of Numerical Method with Prefixed Profile and Machine Learning-based Method for Wet Etching Amount Prediction	Chihiro Matsui The University of Tokyo
14:45	15:05			DA-012	Population estimation of characteristic variation and its application to circuit simulation for power transistors	Haruka Fukumoto ROHM Co.,Ltd
15:05	15:25			DA-017	Prediction of Defect Rate Using Machine Learning in Assembly Process	Yumiko Miyaji Sony Semiconductor Manufacturing
15:25	15:45	Supplier Exhibition / Coffee Break				
Tutorial 2 Speech						
15:45	16:30	Kenji Miyake Office Miyake	Tutorial-2	Chiplet Integration Technology	Prof. Yoichiro Kurita	Tokyo Institute of Technology
Session3						
16:30	16:50	Hirofumi Tsuchiyama INFICON	Shunichi Shibuki Sony Semiconductor Manufacturing	DA-011	Intelligent motor valve with failure prediction feature	Hiroyuki Kawazato Shinwa Controls Co.,Ltd.
16:50	17:10			MEP-010	Development of Versatile Fault Detection Using Image Sensors	Takuya Sugiura Renesas Electronics
17:10	17:30			DA-014	Anomaly detection of semiconductor manufacturing equipment by cluster analysis	Yuki Shiga KOKUSAI ELECTRIC CORPORATION
17:30	17:50			PTL-015	Root Cause Analysis of Plasma Processes Perturbation using Optical Emission Spectroscopy Signals with Modified Autoencoder	Jaehyeon Kim Sungkyunkwan Univ.
17:50	18:00			Closing		
Conference Room						
18:00	18:30	Koichi Sakamoto Tokyo Electron		Author's Interview		
18:30	19:20			Reception & Supplier Exhibition		
19:20	19:30			Best Paper & Student Award		